

Supplementary information for

Berry curvature origin of the thickness dependent anomalous Hall effect in a ferromagnetic Weyl semimetal

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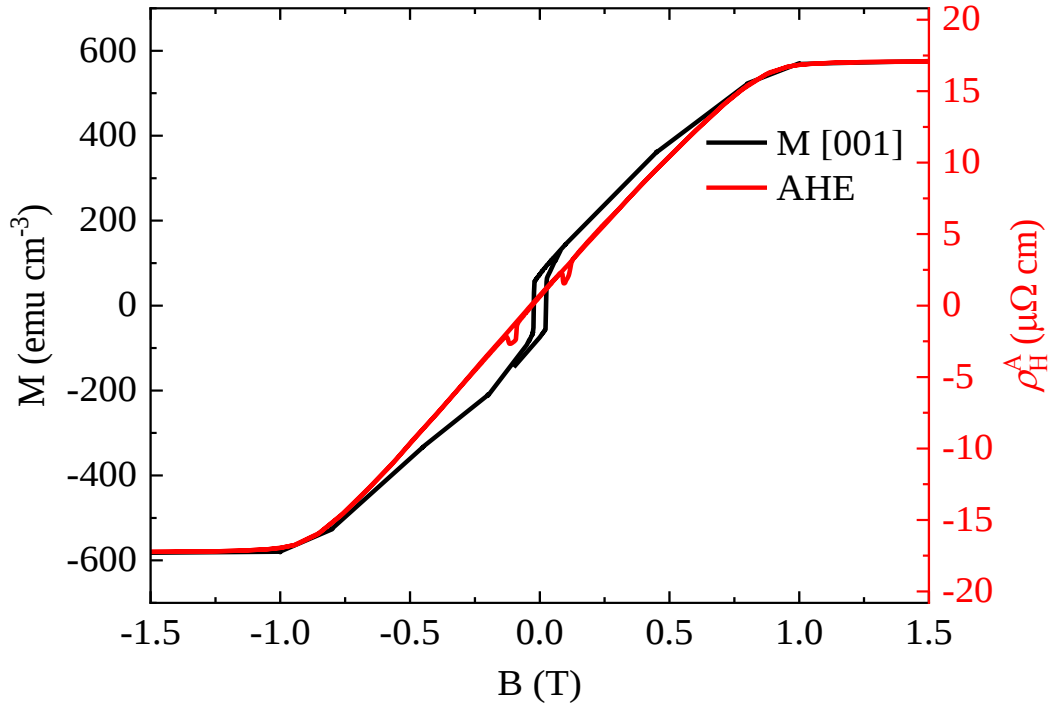
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Supplementary Note 1

Anomalous Hall effect and magnetic hysteresis loop of the Co₂MnGa film

Supplementary Figure 1 presents anomalous Hall effect and magnetic hysteresis loop along out-of-plane of the 50 nm Co₂MnGa film. The saturation field of magnetization along out-of-plane is 1 T in line with the electrical transport measurement. What's more, the loop shows a very small square loop with a coercive field $\mu_0 H_c = 23.6$ mT which is quite small compared with saturation field. One can obtain obvious knots in the resistivity curve which indicating the out-of-plane magnetization component seen in the magnetization measurements.

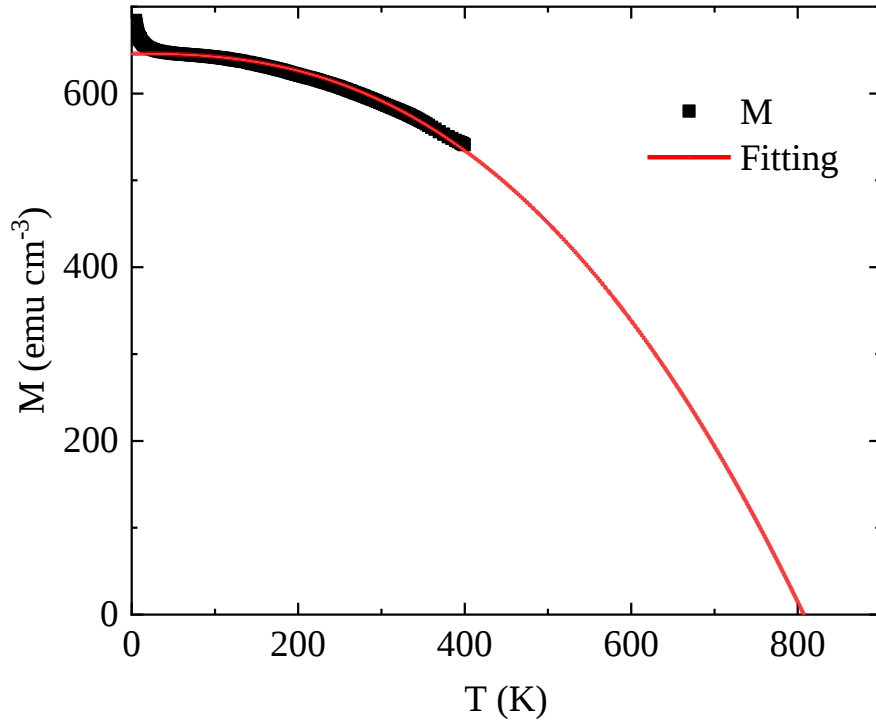


Supplementary Figure 1. Anomalous Hall effect and magnetic hysteresis loop along out-of-plane of the 50 nm Co₂MnGa film measured at 300 K.

Supplementary Note 2

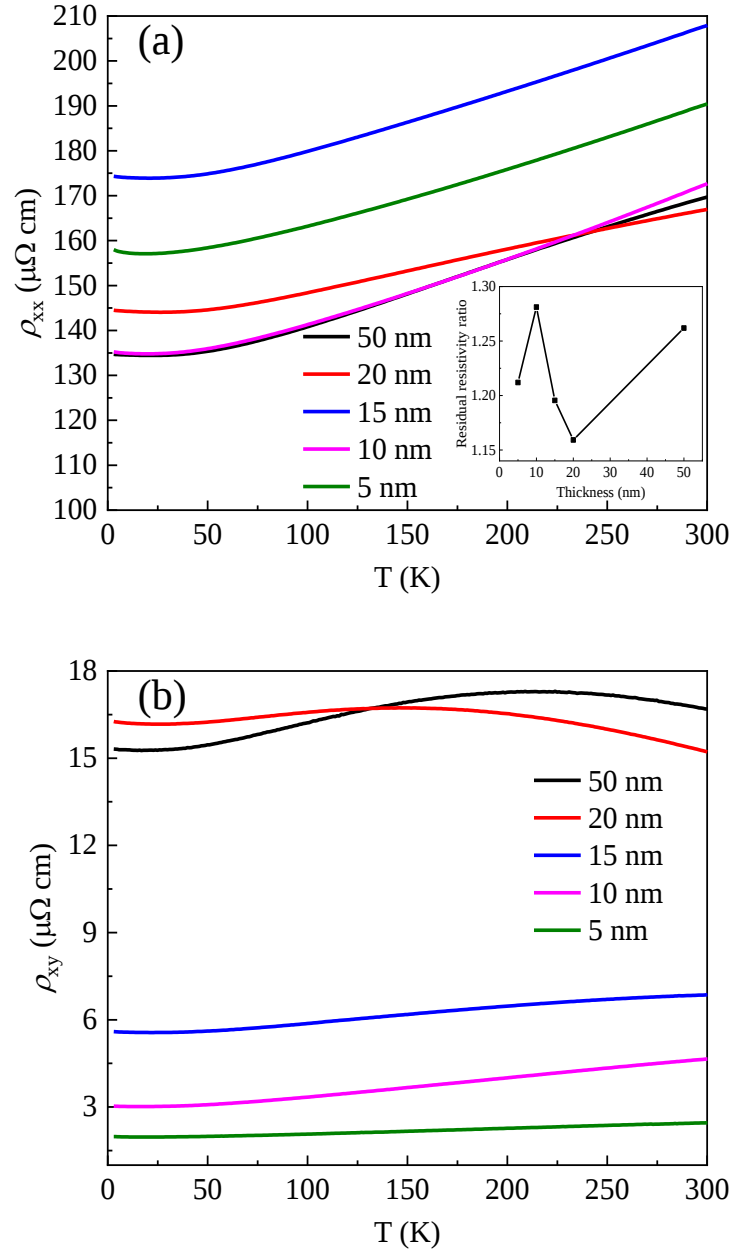
Temperature dependence of magnetization and electrical transport of the Co₂MnGa film

Supplementary Figure 2 presents the temperature dependence of magnetization for the 50 nm Co₂MnGa film. It still shows ferromagnetism at 400 K. The Curie temperature is approximately 800 K as shown by the fit with the extended Bloch law $M = M_s(1 - aT^{5/2})^1$, which is slightly larger than the bulk value ~ 700 K².

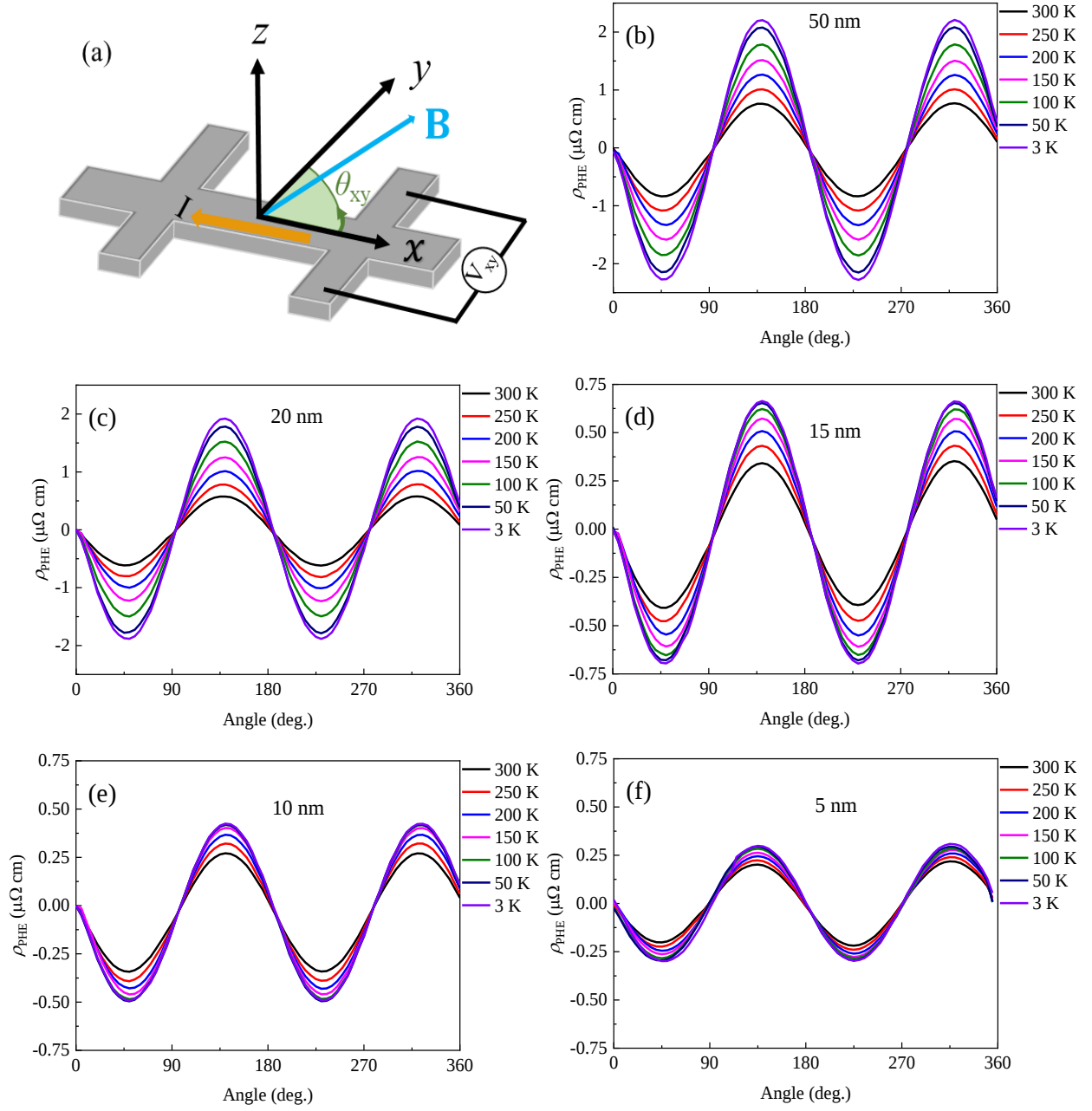


Supplementary Figure 2. Temperature dependence of magnetization for the 50 nm Co₂MnGa film measured from 5 K to 400 K along [110] direction with 50 mT.

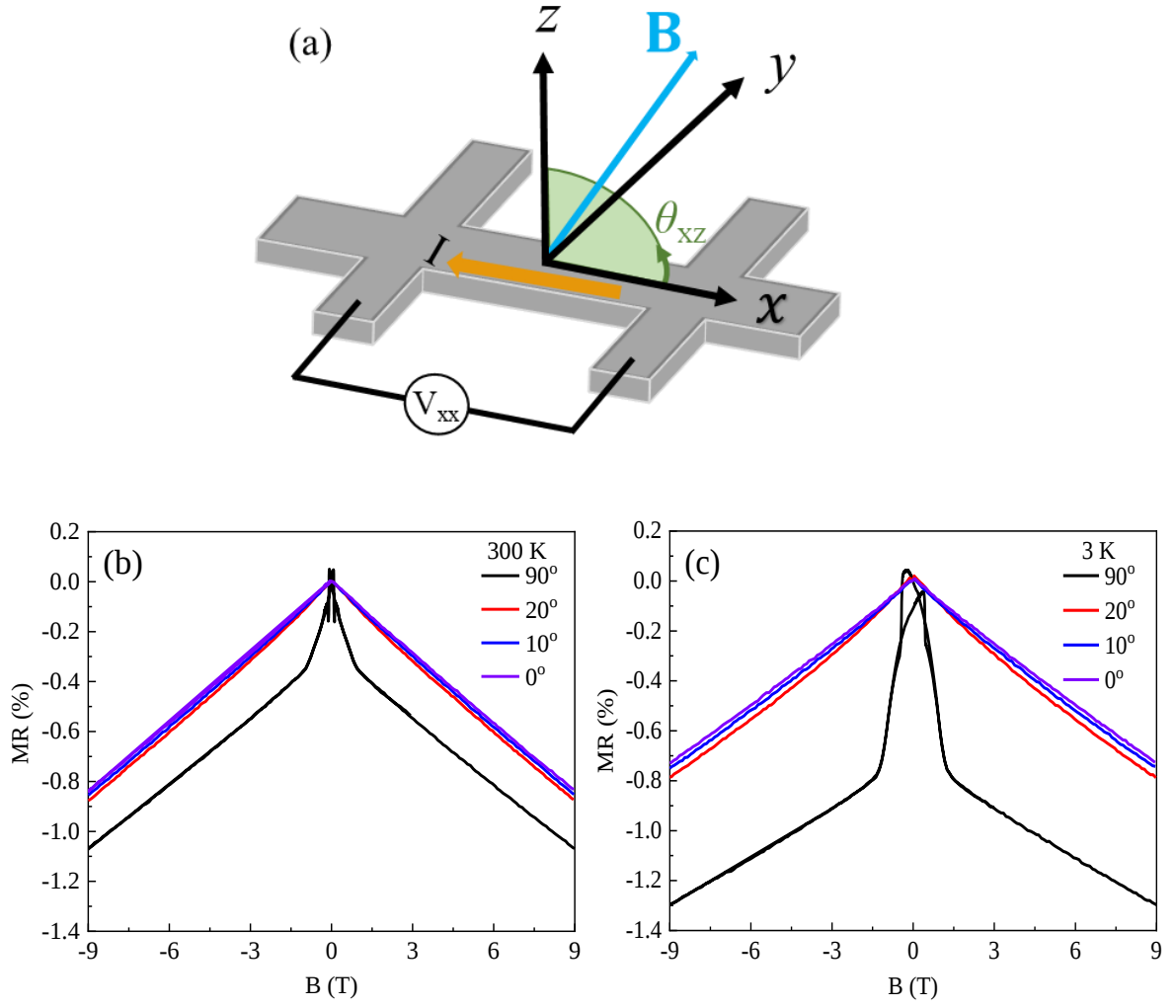
Supplementary Figure 3 shows the ρ_{xx} and ρ_{xy} as a function of temperature from 3 K to 300 K for Co₂MnGa (5-50 nm). The ρ_{xx} is in the range of 167-208 $\mu\Omega$ cm at 300 K for Co₂MnGa (5-50 nm). Especially of note, the ρ_{xx} of 10 nm Co₂MnGa films is almost same as one of 50 nm. This small difference suggests that all films show similar crystalline quality. What's more, the residual resistivity ratios (see inset of Supplementary Figure 3a) of all Co₂MnGa films in our results are similar and even slightly larger than films from previous reports in which a good $L2_1$ -order structure has been confirmed (e.g. 30 nm film in Supplementary Ref. [3] and 80 nm in Supplementary Ref. [4]).



Supplementary Figure 3. (a) Longitudinal resistivity without field as a function of temperature from 3 K to 300 K for Co₂MnGa (5-50 nm). The inset shows the residual resistivity ratio ($\rho_{xx(300K)}/\rho_{xx(residual)}$) as a function of thickness. (b) Anomalous Hall resistivity cooling down in 9 T as a function of temperature from 3 K to 300 K for Co₂MnGa (5-50 nm).



Supplementary Figure 4. Angular dependence of planar Hall resistivity for various thickness of Co_2MnGa film. (a) Schematic of measurement geometry. The angle θ_{xy} represents the angle between the rotating field and x-axis when the field rotates from x-axis to y-axis in the xy plane. Current is along the [100] direction of Co_2MnGa . (b)-(f) planar Hall resistivity as a function of angle, θ_{xy} , measured from 300 K and 3 K under a magnetic field of 9 T for 50, 20, 15, 10 and 5 nm Co_2MnGa film, respectively.

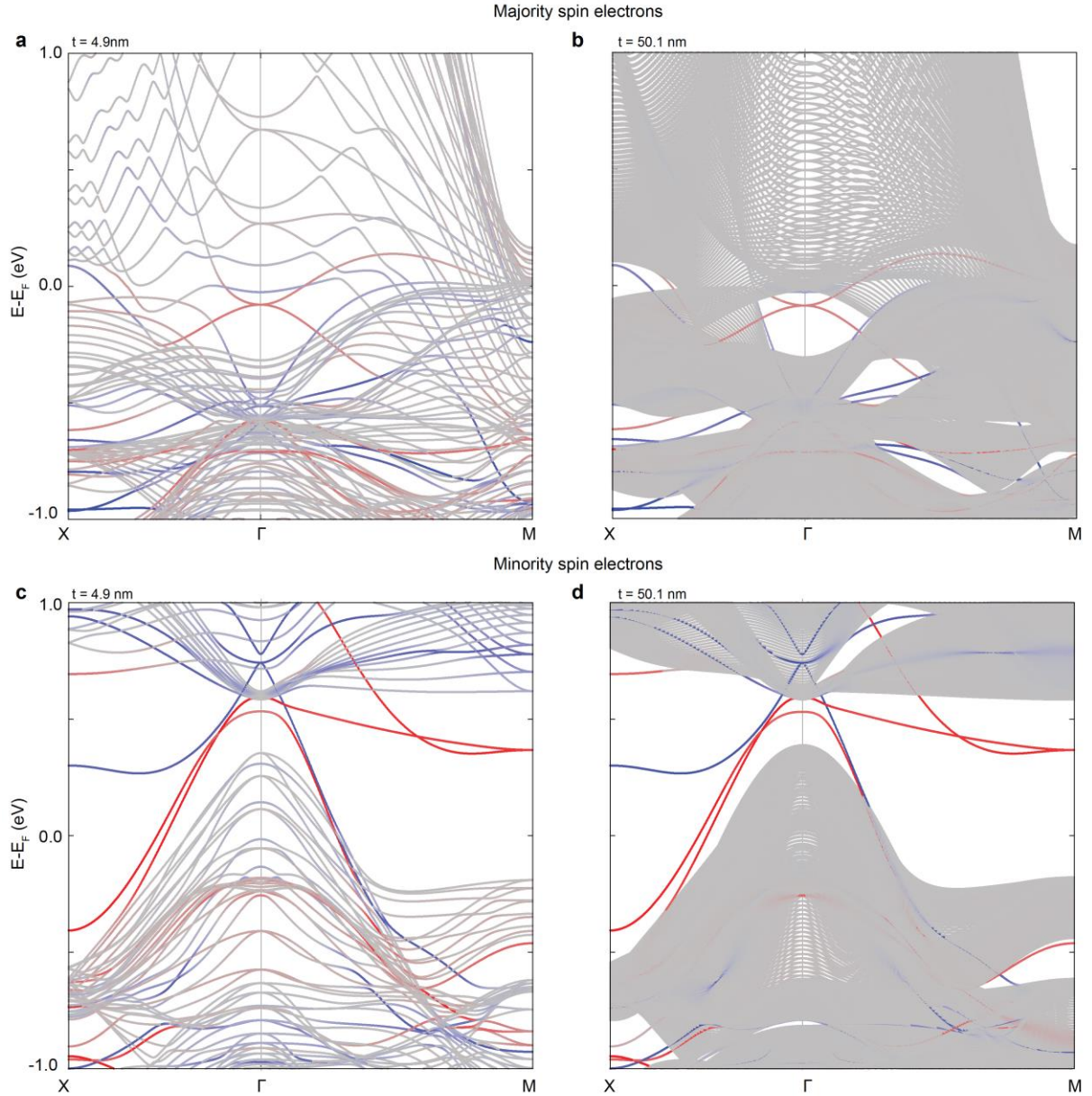


Supplementary Figure 5. Magnetoresistance (MR) ratio of the 50 nm Co_2MnGa film. (a) Schematic of measurement geometry. The angle θ_{xz} represents the angle between the rotating field and x -axis when the field rotates from x -axis to z -axis in the xz plane. Current is along the $[100]$ direction of Co_2MnGa . (b) and (c) MR ratio as a function of magnetic field measured at 300 K and 3 K with various angles, θ_{xz} , respectively.

Supplementary Note 3

Surface band structure of Co₂MnGa

Supplementary Figure 6 presents the Co-terminated and MnGa-terminated surface electronic band structure of 4.9 nm and 50.1 nm Co₂MnGa. Some surface bands from minority spin electrons around the Fermi level are highly isolated from the bulk counterparts independent of film thickness, while the surface character of bands from majority spins, covering by bulk band structure, shows significant changes when film thickness decreases. This could explain the different extent of Berry curvature reduction between majority and minority spin electrons.



Supplementary Figure 6. (001) Surface band structure of Co₂MnGa. The grey bands are bulk bands. The red and blue bands are from Co-terminated surface and MnGa-terminated surface, respectively. (a) and (b) show surface band structure of majority spin electrons for Co₂MnGa thin films of 4.9 nm and 50.1 nm. (c) and (d) show corresponding surface band structure of minority spin electrons.

Supplementary Note 4

The σ_{xy} dependent anomalous Hall angle

Comparison of our anomalous Hall angle results and previously reported data for other magnetic thin films was performed. The reported data were taken from references that can be found in supplementary Table 1.

Materials	$\sigma_{xx}(\Omega^{-1} \text{ cm}^{-1})$	$\sigma_{xy}(\Omega^{-1} \text{ cm}^{-1})$	$\theta_H(\%)$	Refs.
MnGa	5100	288	5.71	5
Mn ₂ Ru _x Ga	2900	220	7.7	6
Co ₂ TiSn	6578.5	51.9	0.79	7
Co ₂ Ti _{0.6} V _{0.4} Sn	1602.4	13.9	0.87	7
L1 ₀ -FePt	37900	1250	3.3	5
TbCo	25000	800	3.2	5
SmFe	6600	317	4.8	5
FeGd	5111	295	5.8	8
GaMnAs	2200	147	6.6	5
SrRuO ₃	20000	200	1	5
Fe	43600	1134	2.6	9
Co, Ni	100000	500	0.06	9
Gd	500000	1000	0.2	9
Pt/Py	23800	380	1.6	10
Pt/Co multilayers	24376	595	2.3	11
Mn ₅ Ge ₃ C _{0.8}	3326	155	4.7	12
Co ₃ Sn ₂ S ₂	3850	770	20	13
Co₂MnGa	6805.2	774.4	11.4	Present work

Supplementary Table 1. Summary of σ_{xx} , σ_{xy} , and θ_H of magnetic thin films. Only the maximum values of θ_H are adopted here.

Supplementary References

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